



INTERNATIONAL  
GEMOLOGICAL  
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

October 7, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

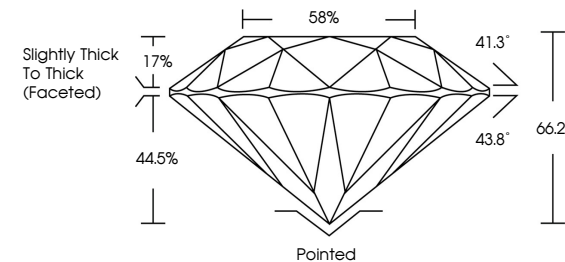
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG844682657

Report verification at [igi.org](#)

PROPORTIONS



Slightly Thick To Thick (Faceted)

58%

41.3°

43.8°

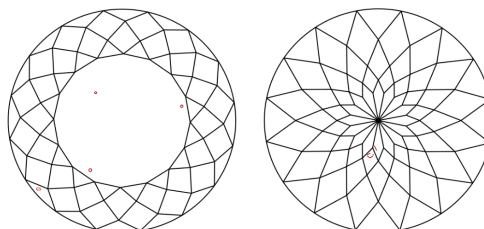
66.2%

44.5%

17%

Pointed

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

COLOR

|   |   |   |   |   |   |   |       |            |       |
|---|---|---|---|---|---|---|-------|------------|-------|
| D | E | F | G | H | I | J | Faint | Very Light | Light |
|---|---|---|---|---|---|---|-------|------------|-------|

CLARITY

|          |                     |                             |                        |                   |                  |
|----------|---------------------|-----------------------------|------------------------|-------------------|------------------|
| FL       | IF                  | VS <sup>1-2</sup>           | VS <sup>1-2</sup>      | SI <sup>1-2</sup> | I <sup>1-3</sup> |
| Flawless | Internally Flawless | Very Very Slightly Included | Very Slightly Included | Slightly Included | Included         |



Sample Image Used

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EXCELLENT

EXCELLENT

NONE

LG844682657



IGI

October 7, 2026

IGI Report No LG844682657

ROUND MIXED CUT

8.15 - 8.14 X 5.39 MM

2.50 CARATS

E

VS 2

66.2%

85%

Slightly Thick To Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

LG844682657

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